



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Robert Bristol et al.

Serial No.: 10/679,816

Filed: October 6, 2003

For: Enhancing Photoresist Performance
Using Electric Fields

§ Group Art Unit:

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Examiner:

Atty. Dkt. No.: ITL.1023US (P16710)

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

INFORMATION DISCLOSURE STATEMENT


Dear Sir:

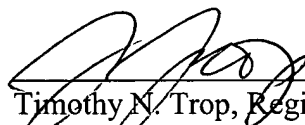
Applicant submits the references listed on the attached form PTO 1449 together with any required copies of such references.

This statement is being filed within three months of the filing date of the application.
Please apply any charges or credits to Deposit Account No. 20-1504 (ITL.1023US).

Respectfully submitted,

Date:

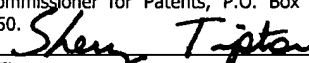

12/30/03

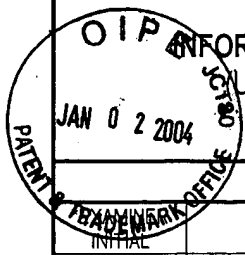


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Date of Deposit: December 30, 2003

I hereby certify under 37 CFR 1.8(a) that this correspondence is being deposited with the United States Postal Service as **first class mail** with sufficient postage on the date indicated above and is addressed to the Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450.


Sherry Tipton



INFORMATION DISCLOSURE CITATION (Use several sheets if necessary)	ATTY DOCKET NO. ITL1023US (P16710)	SERIAL NO. 10/679,816
	APPLICANT(S): ROBERT BRISTOL ET AL.	
	FILING DATE: October 6, 2003	GROUP ART UNIT:

U.S. PATENT DOCUMENTS

INITIAL		DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
	A.	5,158,861	10/27/1992	TOKUI ET AL.	430	325	
	B.						
	C.						
	D.						
	E.						
	F.						
	G.						
	H.						
	I.						

FOREIGN PATENT DOCUMENTS

		DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION	
							YES	NO
	J.							
	K.							
	L.							
	M.							
	N.							
	O.							
	P.							

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

	Q.	Cheng et al., "Improving Resist Resolution and Sensitivity Via Electric-Field Enhanced Postexposure Baking", J. Vac. Sci. Technol. B 20(2), Mar/Apr 2002
	R.	
	S.	
	T.	
	U.	
	V.	
	W.	

EXAMINER	DATE CONSIDERED
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*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

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